Attorney Docket No.: P1031 - LAM



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

18/17/05 -

Applicant(s): Annapragada et al.) Group Art Unit: 2813

Application Serial No.: 10/712,326) Examiner: Nguyen, Thanh T

Filed: November 12, 2003

Title: Minimizing the Loss of Barrier Materials During Photoresist

Stripping

AMENDMENT AND RESPONSE TO OFFICE ACTION

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Dear Sir/Madam:

This Amendment and Response is submitted in response to the Office Action dated May 16, 2005 in the above referenced patent application. A one-month extension is filed herewith. Please enter and consider the following amendments and remarks.

Amendments to the Claims are reflected in the listing of claims which begins on Page 2 of this paper.

Remarks begin on page 8.